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Vacuum technology — Standard methods for measuring vacuum-pump performance — Part 5: Non-evaporable getter (NEG) vacuum pumps

~~Élément introductif — Élément central — Partie 5: Élément complémentaire~~

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Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular, the different approval criteria needed for the different types of ISO documents should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

Attention is drawn to the possibility that some of the elements of this document may be the subject of patent rights. ISO shall not be held responsible for identifying any or all such patent rights. Details of any patent rights identified during the development of the document will be in the Introduction and/or on the ISO list of patent declarations received (see www.iso.org/patents).

Any trade name used in this document is information given for the convenience of users and does not constitute an endorsement.

For an explanation of the voluntary nature of standards, the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT), see www.iso.org/iso/foreword.html.

This document was prepared by Technical Committee ISO/TC 112, *Vacuum technology*.

A list of all parts in the ISO 21360 series can be found on the ISO website.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at www.iso.org/members.html.

Introduction

This document specifies methods for measuring the performance data of non-evaporable getters (NEGs) with the shape of pill, disk, ring, strip, module, cartridge, pump structures and coatings. This document complements ISO 21360-1, which provides a general description of the measurement of performance data of vacuum pumps.

The methods described here are well known from existing national and international standards. This document aims to show a collection of suitable methods for the measurement of performance data of NEGs. ~~Apply the~~The method specified in this document ~~instead of~~takes precedence over the volume flow rate (pumping speed) measurement ~~shown~~given in ~~the section of~~ISO 21360-1:2020, 5.1, 5.2 and 5.3 ~~of ISO 21360-1~~.

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Vacuum technology — Standard methods for measuring vacuum-pump performance — Part 5: Non-evaporable getter (NEG) vacuum pumps

1 Scope

This document specifies methods for the measurement of pumping characteristics of non-evaporable getters (NEGs). It is applicable to all sizes and all types of NEGs, including those:

- with the shape of pill, disk, ring, strip, module, cartridge;
- with pump structures;
- and NEG coatings on inner surface of pipes and vacuum chamber.

A significant difference of pumping characteristics of NEG with other vacuum pumps is that the pumping speed of NEG depends on the sorption quantity. ~~Besides~~Furthermore, especially in the case of NEG coating, the sticking probability rather than the pumping speed ~~is~~ often ~~is~~ the index of the pumping performance. Therefore, this document specifies the methods for measuring the pumping speed, the sorption quantity, and the sticking probability of NEGs.

WARNING It is assumed that the user is familiar with ~~ultra-high vacuum technology and~~ the handling of combustible gases and ~~poison~~poisonous ones ~~and with ultra-high vacuum technology~~.

2 Normative references

There are no normative references in this document.

3 Terms and definitions

For the purposes of this document, the following terms and definitions apply.

ISO and IEC maintain terminology databases for use in standardization at the following addresses:

- ISO Online browsing platform: available at ~~https://www.iso.org/obp~~<https://www.iso.org/obp>
- IEC Electropedia: available at ~~https://www.electropedia.org/~~<https://www.electropedia.org/>

3.1

non-evaporable getter

NEG

getter material to sorb gases in vacuum chambers without evaporation

Note 1 to entry: Sorbing gases mean the process of removing gases from vacuum chambers by adsorption or absorption phenomena. The adsorption is a kind of sorption in which the gas is retained at the surface of the getter material. Most of gas molecules are chemisorbed at the surface of the getter material. The absorption is also a kind of sorption in which the gas molecules diffuse into the bulk of the getter material. The term of “sorption”, “adsorption”, “chemisorption” and “absorption” are defined at ISO 3529 1:2019, 3.4.1, 3.4.2, 3.4.4 and 3.4.6, respectively.

Note 2 to entry: ~~NEG has in~~NEGs have a variety of forms, such as pellets (pills), bars, chips, powders, sheets, strips, washers, wires, module and cartridge.

3.2 non-evaporable getter vacuum pump NEG vacuum pump

entrapment vacuum pump with a reactive porous alloy or powder mixtures getter material

[Source: ISO 3529-2:2020, 3.1.36]

Note 1 to entry: non-evaporable getter vacuum pumps are mounted on a vacuum flange in typical. The internal heaters and the controller for the activation may be included.

3.3 non-evaporable getter coating NEG coating

thin films made from non-evaporable getter, which is coated on inner surface of pipes and vacuum chamber

3.4 surface getter

getter where only the surface shows pumping action

Note 1 to entry: The pumping speed and sorption capacity are essentially proportional to the surface area.

Note 2 to entry: For example, Zr-Fe-V alloy acts as a surface getter for CO at room temperature.

3.5 volume getter

getter where the pumping speed and/or sorption capacity depends on the volume

Note 1 to entry: The dependence of the pumping speed and sorption capacity of the volume getters on the temperature and operation pressure is more significant compared with the *surface getter* (3.4).

Note 2 to entry: For example, Zr-Fe-V alloy acts as a volume getter for H₂ at room temperature. Zr-Fe-V alloy also acts as a volume getter for CO at high temperature.

3.6 activation

conditioning by thermal treatment of a getter to develop its gettering characteristics

Note 1 to entry: Hydrogen reversibly acts with non-evaporable getters (NEGs) and therefore allows to be released by activation.

Note 2 to entry: Other active gases such as CO, CO₂, N₂, and O₂ are chemisorbed irreversibly with NEG. The activation promotes the diffusion of these gas atoms into the bulk.

3.7 getter pumping speed

S
volume of gas sorbed per unit time

Note 1 to entry: The pumping speed is the same meaning of the volume flow rate.

Note 2 to entry: Getter pumping speed depends on gas species and the amount of gas being sorbed.

3.8**initial pumping speed of getter (or NEG)**

instantaneous pumping speed 3 min after the start of the test at the chosen pressure and temperature

Note 1 to entry: This time delay is necessary to allow initial transient effects, until the pressure equilibrium has become negligible.

3.9**intrinsic sticking probability****sticking coefficient**

ratio of the number of sorbed gas molecules to that of impinging ones at a unit area per unit time, where the surface is assumed to be flat.

3.10**sticking probability**

α

ratio of the number of sorbed gas molecules to that of impinging ones at a unit apparent area per unit time

Note 1 to entry: Sticking probability depends on gas species, surface chemical composition, surface roughness and coverage.

Note 2 to entry: Sticking probability is typically measured as pumping characteristics of NEG~~s~~.~~3-11~~

3.11**sorption quantity**

C_q

quantity of gas sorbed by the getter

3.12**sorption capacity**

C_c

quantity of gas sorbed by the getter until the getter pumping speed decrease to 10 % of the initial pumping speed

4 Symbols and abbreviated terms

| Symbol | Designation | Unit |
|--------|--|-----------|
| A | apparent surface area of getter material | m^2 |
| C_0 | conductance of orifice | m^3/s |
| C_q | sorption quantity | $Pa\ m^3$ |
| C_c | sorption capacity | $Pa\ m^3$ |
| F_1 | correction factor of vacuum gauge 1, where $F_1 = 1/K_1$ | |
| F_2 | correction factor of vacuum gauge 2, where $F_2 = 1/K_2$ | |

| | | |
|------------|--|----------------------|
| K_1 | sensitivity of vacuum gauge 1 | |
| K_2 | sensitivity of vacuum gauge 2 | |
| p_{R1} | pressure reading of vacuum gauge 1, which is located at the upstream side of orifice | Pa |
| p_{R2} | pressure reading of vacuum gauge 2, which is located at the downstream side of orifice | Pa |
| p_{B1} | base pressure of vacuum gauge 1 | Pa |
| p_{B2} | base pressure of vacuum gauge 2 | Pa |
| Q_{pv} | gas flow rate | Pa m ³ /s |
| Q_{mol} | molar flow rate | mol/s |
| R | ideal gas constant | 8,134 J/(mol K) |
| S | getter pumping speed | m ³ /s |
| T | temperature | K |
| α | sticking probability | - |
| α_0 | initial sticking probability | - |

5 Test methods

5.1 General

5.1.1 Test gases

H₂ and CO shall be used to test for NEG. CO can be replaced ~~to~~by N₂ or CO₂ from ~~the~~a safety ~~issue~~perspective when an agreement is made between customer and testing laboratory. In addition, other gases such as O₂ can be required depending on the application. The purity of the test gas in the gas cylinder shall be higher than 99,99 % for H₂ and 99,95 % for CO, respectively. It is also recommended to measure the purity of the test gas by using quadrupole mass spectrometer (QMS) in the vacuum chamber because the test gas can be polluted during the transportation from the gas cylinder to the vacuum chamber.

5.1.2 Vacuum chamber

The vacuum chamber shall consist of all-metal vacuum components with a baking system. When the valves of elastomer sealing parts are used, they shall be bakeable and fabricated for the usage of UHV condition. The cleanliness shall be appropriate to obtain sufficiently low base pressure in the range of ultrahigh vacuum or extreme-high vacuum (XHV). The apparatus shall be capable of reaching a base pressure of less than 1×10⁻⁶ Pa without NEG sample installation or with uncoated tube. In addition, it is recommended to measure the residual gas by QMS to make sure that both the air leak and the outgassing of H₂O, CO, CO₂, and hydrocarbons are sufficiently small.

NOTE—Note that H₂ should be the dominating gas species at the base pressure.